I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents and Trademarks, Alexandria, VA. 22313, on October 18, 2004. The applicant and/or attorney requests the date of deposit as the filing date. Depositor: Nicole Barrese

(Signature & date)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

October 15, 2004

Venigalla, et al. :

Group Art Unit: To be Assigned

Serial No. 10/711,369

Examiner: To Be Assigned

Filed: 9/14/04

International Business Machines Corporation 2070 Route 52

Hopewell Junction, NY 12533

TITLE:

CERIA-BASED POLISH PROCESSES AND CERIA-BASED SLURRIES

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Pursuant to the duty of disclosure set forth in 37 C.F.R. 1.56, and further pursuant to the provisions of 37 C.F.R. 1.97 and 1.98, applicants hereby respectfully submit copies of the non-US patents and publications as listed on Form PTO-1449, attached hereto.

In citing these documents, no representation is made nor intended as to the pertinency or nonpertinency of the art, that better art than that listed is not available, or that other art is not applicable.

No fee is believed to be due for this submission. If any fees are required, however, the Commissioner is hereby authorized to charge such fees to Deposit Account No. 09-0458.

Respectfully submitted,

Venigalla, et al.

H. Daniel Schaumann-Registration No. 35,791

Telephone No. 845-894-2481

10/711,369

FIS920040210US1

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